	Application No.	Applicant(s)		
	10/065,302	HENDRICKS, NEIL H.		
Notice of Allowability	Examiner	Art Unit)	
	Olivia T Luk	2812	Pr	
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RECORD TO THE OFFICE OF Upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this apport of the communication GHTS. This application is subject to	plication. If not include n will be mailed in due o	d course. THIS	
1. This communication is responsive to 10/27/04.				
2. 🔀 The allowed claim(s) is/are <u>1-44</u> .				
3. X The drawings filed on <u>01 October 2002</u> are accepted by the	e Examiner.			
4. Acknowledgment is made of a claim for foreign priority una All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have 3. Copies of the certified copies of the priority documents not international Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONMI THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be submited in INFORMAL PATENT APPLICATION (PTO-152) which give 6. CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftsperson 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1.1.2.2.2.2.2.2.2.2.2.2.2.2.2.2.2.2.2.2	been received. been received in Application No cuments have been received in this of this communication to file a reply ENT of this application. tted. Note the attached EXAMINER is reason(s) why the oath or declara t be submitted. on's Patent Drawing Review (PTO- c Amendment / Comment or in the Comment or in the Comment of the drawing he header according to 37 CFR 1.121(content).	national stage applicational stage applicational stage application complying with the requirement of the latest action of the latest ac	uirements OTICE OF	
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/08 Paper No./Mail Date 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	5. Notice of Informal P 6. Interview Summary Paper No./Mail Dat 7. Examiner's Amendr 8. Examiner's Stateme 9. Other	(PTO-413), te ment/Comment		

Application/Control Number: 10/065,302

Art Unit: 2812

DETAILED ACTION

Allowable Subject Matter

- 1. Claims 1-44 are allowed.
- 2. The following is an examiner's statement of reasons for allowance: Prior art of record teach precursor compositions for CVD formation of low k dielectric films comprising an aromatic compound, but fail to teach at least one unsaturated constituent that is ethylenically and/or acetylenically unsaturated. Most precursor compounds are not in gaseous form but solvent form. Prior art of record teach aromatic compounds, but in combination with one of an alkyl, alkoxy, or heterocyclic compound. Lee et al. teach forming precursor compounds to make materials with low dielectric constant with chemical vapor deposition with a polymer comprising an aromatic, but again, wholly fail to teach an unsaturated constituent that is ethylenically and/or acetylenically unsaturated.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

3. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. References not applied are considered state of the art in the area of semiconductor manufacture.

Application/Control Number: 10/065,302

Art Unit: 2812

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Olivia T Luk whose telephone number is 571-272-1676. The examiner can normally be reached on 7AM to 4PM Mon-Fri.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling can be reached on 571-272-1679. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

OTL

October 29, 2004

John F. Niebling

Supervisory Patent Examiner Technology Center 2800